



1/4" HIGH PRESSURE GAS FILTER F1D10286-01

DESCRIPTION

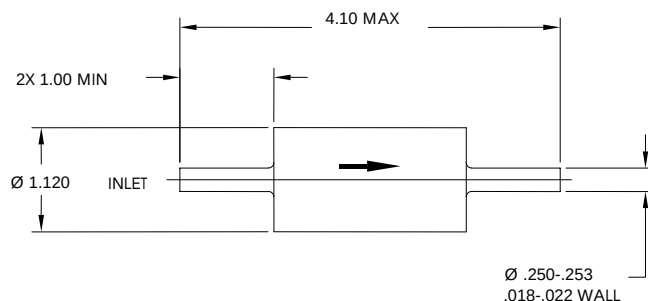
VACCO Industries maintains a product line of flight qualified etched disc filters, providing absolute filtration for satellites and spacecraft since 1961.

The etched disc filter's superior characteristics are due to several features. First, each flow path is chemically etched into metal by a high precision photochemical- etching process. Next, each disc is individually cleaned prior to assembly in a clean room. Finally, no welding is performed on the stack element assembly assuring the cleanest and most reliable filter in the industry.



FEATURES

- ⊕ Etched Disc Technology
- ⊕ All Titanium Construction with Titanium Etched Disc Assembly
- ⊕ Weight – 114g/0.25 lbm
- ⊕ 10 Micron Absolute Filtration
- ⊕ 4200 psig Operating Pressure



OPERATING PARAMETERS

Operating Pressure Range 4200 psig
 Proof Pressure 6300 psig
 Burst Pressure 16800 psig
 Flow Rate 4 scfm GHe
 Pressure Drop (Clean) <1 psid @ rated flow
 (Dirty).....<1 psid (max.) with 100 mg @ rated flow

External Leakage..... <1 x 10⁻⁶ sccs GHe
 Weight..... 0.25 lbm (114 grams)
 Operating Temperature +10° to +170° F
 Filtration Rating..... 10 microns absolute
 Random Vibration 25.32 G(rms), 3 min/axis

PERFORMANCE CHARACTERISTICS

Flow vs Pressure Drop

